ANNEALSYS

MC-100

Low cost MOCVD reactor for Research and Development

APPLICATIONS

Metal and Alloys, Transition Metal Nitrides, Oxides, Carbon Nanotubes, ...

- Semiconductor: SiO₂, HfO₂, Ta₂O₅, Cu, TiN, TaN
- High k Dielectric: SrTiO₃, BaTiO₃, Ba_(1-x)Sr_xTiO₃ (BST)
- Ferroelectric: SBT, SBTN, PLZT, PZT,...
- Superconductor: YBCO, Bi-2223, Bi-2212, Tl-1223, ...
- Piezoelectric: (Pb, Sr)(Zr,Ti)O₃, Modified Lead Titanate
- Colossal Magneto Resistance
- Thermal coatings
- Buffer layers
- Mechanical coatings
- Optics
- Etc...

SPECIFICATIONS

The Annealsys MC100 is a 4-inch thermally controlled wall CVD reactor especially developed to meet the requirements of research and development units for MOCVD and Spray CVD processes.

The MC100 allows doing heteroepitaxy of oxides on single crystals wafers (such as YBCO/LAO, STO/MgO, MxOy/LAO...) by MOCVD using a wide range of solid and liquid organometallic volatile precursors.

The MC100 systems can be provided with various vaporization systems and vacuum equipment depending on the application. The direct injection vaporizer allows the widest range of utilization of precursor to develop new materials

PERFORMANCE CHARACTERISTICS

- Temperature range: RT to 850 C
- Up to 4 vaporizers
- Vacuum range: Atmosphere to 10-3 Torr



www.sivaley.com

Specifications are subject to change without notice. Non-contractual document – AS5B14

ANNEALSYS

MC-100

General features

Maximum substrate diameter 4-inch

Process chamber Stainless steel with thermally controlled walls

Rotating substrate holder

Heating Resistor heating

Temperature control Thermocouple temperature control

Digital PID temperature controllers

Vacuum, gas and liquid Purge gas line with needle valve

Up to 6 process gas lines with mass flow controllers

Up to 4 vaporizer units selected function of liquid precursors

Custom liquid panel depending on the application

Vacuum valve and vacuum gauge Optional vacuum rotary of dry pump

Optional pressure control with throttle valve

Control Full PC control

Facilities Electricity: 3x400V+N+Gr or 3x220V+Gr, 50/60 Hz

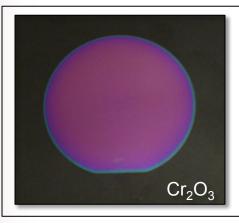
Power: 12 kW

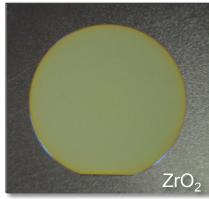
Water: 2 to 6 bars, pressure drop 1 bar, 4 l/mn Compressed air: 6 bars (valve actuation)

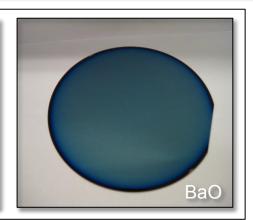
Process gas fittings: Swagelok ¼ (VCR ¼ optional)

Dimensions and weight Width: 1100 mm

Depth: 1450 mm
Height: 2000 mm
Weight: 800 kg







www.sivaley.com

SIVALEY, INC.

3652 Edison Way Fremont, CA94538, USA

TEL: +1-408-887-7391 FAX: +1-510-353-1809

EMAIL: sales@sivaley.com